

Reg No.: \_\_\_\_\_

Name: \_\_\_\_\_

**APJ ABDUL KALAM TECHNOLOGICAL UNIVERSITY**

M.Tech S1 (R,S) Exam Dec 2020

Cluster: **Kollam**Branch: **Electrical and Electronics Engineering**Specialisation: **Industrial Instrumentation and Control****02EE6121 PROCESS DYNAMICS AND CONTROL**

Time: 3 Hrs

Max. Marks: 60

**PART A***(Answer All Questions)*

1. List the necessity for modeling of dynamic systems in a process industry.
2. Develop the dynamic model for a Chemical Reactor control system.
3. Explain Zeigler Nichols Closed loop tuning technique of controllers.
4. Explain transmitters used in process instrumentation. **(4 x 9=36)**

**PART B***(Answer Any Two from each question)*

5. (a) Explain with schematic diagram Direct Digital Control (DDC) for a process control industry.  
(b) Explain with neat block diagram Data Acquisition System.  
(c) Explain with schematic diagram Supervisory control for a process control industry.
6. (a) List the important characteristics of a control loop.  
(b) Explain Internal model controller used for the control of a process model.  
(c) Explain typical measuring device used for a temperature and pressure process control.

**(2 x 12=24)**

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